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Dental Engineering: Materials, Technologies and Devices for Dentistry 4.0

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Deadline for manuscript submissions:

closed (30 September 2023)

Message from the Guest Editors

In the case of dental engineering, a very important role is played by the correct material design in relation to the biomaterials used, as well as the dissemination of the application of additive technologies for the manufacturing of implants, prosthetic restorations, and additional equipment used in clinical practice, including surgical templates and accessories facilitating the assembly of implants. The use of nanotechnology, e.g., in the use of nanostructured or nanocomposite materials, and the use of nano coatings, e.g., using the atomic layer deposition ALD methods as well as nanodots is worth considering. The intention of the editors of this Special Issue is to compile a very wide collection of studies that can be treated as a kind of compendium of modern dental engineering. We invite you to participate in co-creating this ambitious project.











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Message from the Editor-in-Chief

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